

# ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

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## Title of Invention

GENERATING MASK PATTERNS FOR ALTERNATING  
PHASE-SHIFT MASK LITHOGRAPHY

Application Number : *10 604573*

Confirmation Number: \_\_\_\_\_

First Named Applicant: Lars Liebmann

Attorney Docket Number: FIS920020113

Art Unit: *2825*

Examiner: *Dinyan*

Search string: ( 5807649 or 6258493 or 6338922 or 20020071997 or 20020045136 or  
20020083410 or 20020081500 or 20020094492 or 20010028985 ).pn

## US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

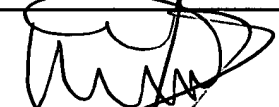
init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
<i>H70</i>	1	5807649	1998-09-15	Liebmann et al.	<i>—</i>		
<i>1</i>	2	6258493	2001-07-10	Wang et al.	<i>—</i>		
<i>3</i>	3	6338922	2002-01-15	Liebmann et al.	<i>—</i>		

## US Published Applications

Note: Applicant is not required to submit a paper copy of cited US Published Applications

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
<i>H70</i>	1	20020071997	2002-06-13	Ahrens et al.	<i>—</i>		
<i>2</i>	2	20020045136	2002-04-18	Fritze et al.	<i>—</i>		
<i>3</i>	3	20020083410	2002-06-27	Wu et al.	<i>—</i>		
<i>4</i>	4	20020081500	2002-06-27	Cobb et al.	<i>—</i>		
<i>5</i>	5	20020094492	2002-06-18	Randall et al.	<i>—</i>		
<i>6</i>	6	20010028985	2001-10-11	Wang et al.	<i>—</i>		

Signature



Examiner Name

*MAGID DINYAN*

Date

*07/29/05*